

## UNITED STATES PATENT AND TRADEMARK OFFICE



APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/114,203	07/13/1998	ATSUSHI MIYANISHI	030682-066	8932
21839 7	590 10/16/2002			
BURNS DOANE SWECKER & MATHIS L L P			EXAMINER	
POST OFFICE BOX 1404 ALEXANDRIA, VA 22313-1404		BAUMEISTER, BRADLEY W		
			ART UNIT	PAPER NUMBER
			2815	

DATE MAILED: 10/16/2002

Please find below and/or attached an Office communication concerning this application or proceeding.

# Office Action Summary

Application No. **09/114,203** 

Applicant(s)

Miyanishi et al.

Examiner

**B. William Baumeister** 

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	The MAILING DATE of this communication appears	on the cover sheet with the correspondence address			
	for Reply				
	ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION.	TO EXPIRE 3 MONTH(S) FROM			
		no event, however, may a reply be timely filed after SIX (6) MONTHS from the			
	g date of this communication. period for reply specified above is less than thirty (30) days, a reply within th	ne statutory minimum of thirty (30) days will be considered timely.			
- If NO	period for reply is specified above, the maximum statutory period will apply a	and will expire SIX (6) MONTHS from the mailing date of this communication.			
- Any re	to reply within the set or extended period for reply will, by statute, cause the ply received by the Office later than thee months after the mailing date of t				
earned Status	l patent term adjustment. See 37 CFR 1.704(b).				
1) 💢	Responsive to communication(s) filed on 7/25/02 a	and 8/14/02 .			
2a) 💢	This action is <b>FINAL</b> . 2b) ☐ This act	ion is non-final.			
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.				
Disposition of Claims					
4) 💢	Claim(s) 2-4, 6-11, and 13-24	is/are pending in the application.			
4	a) Of the above, claim(s) 2-4 and 6-11	is/are withdrawn from consideration.			
5) 🗆	Claim(s)	is/are allowed.			
6) 💢	Claim(s) <u>13-24</u>	is/are rejected.			
7) 🗆	Claim(s)	is/are objected to.			
8) 🗆	Claims	are subject to restriction and/or election requirement.			
Application Papers					
9) $\square$ The specification is objected to by the Examiner.					
10)	10) ☐ The drawing(s) filed on is/are a) ☐ accepted or b) ☐ objected to by the Examiner.				
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).				
11)💢	The proposed drawing correction filed on	5, 2002 is: a) $\square$ approved b) $\square$ disapproved by the Examiner.			
If approved, corrected drawings are required in reply to this Office action.					
12)	12) The oath or declaration is objected to by the Examiner.				
Priority under 35 U.S.C. §§ 119 and 120					
13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a) □ All b) □ Some* c) □ None of:					
	1. Certified copies of the priority documents have been received.				
	2. Certified copies of the priority documents have been received in Application No				
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).					
-	ee the attached detailed Office action for a list of the	e certified copies not received.			
14)	14) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).				
a) The translation of the foreign language provisional application has been received.					
15)	Acknowledgement is made of a claim for domestic	priority under 35 U.S.C. §§ 120 and/or 121.			
Attachm		r			
_	trice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper No(s).			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  5) Notice of Informal Patent Application (PTO-152)  3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)					
3) [] Int	omation Disclosure Statement(s) (PTO-1449) Paper No(s).	6) L_J Otner:			

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#### **DETAILED ACTION**

### Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 13, 17-19, 23 and 24 rejected under 35 U.S.C. 103(a) as obvious over Shou et al. '859 in view of NSC WO '898.
- a. Shou depicts inverter circuits having various active regions including PL1 and NL1. See e.g., PL1 wherein a recessed region (strangulation region S1) is disposed between two ordinary regions. The left portion of the ordinary region has a first gate electrode G disposed between S/D regions having contacts C1 and C3, respectively. The strangulation region has a second gate electrode G. Both of these gates have upper ends which are formed in a line.

While the reference unequivocally depicts the two gates terminating at a common line, the reference does not expressly depict this common line being at a point that is beyond the edge of the active region PL1 (i.e., the reference does not expressly depict the presence of end caps). Nonetheless, one skilled in the art would understand that the gate of the ordinary region must necessarily extend at least some distance onto the surrounding oxide region (i.e., that the end caps must necessarily be present on both gates); otherwise the source/drain regions of the ordinary

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region would be inclined to short and the transistor would not operate as intended. Thus, Shou inherently discloses the presence of the end caps.

- b. Alternatively, even assuming *arguendo* that Shou must be interpreted so narrowly as not expressly teaching the presence of the end cap on the ordinary region, the claims would be obvious since its presence is implied. Further, NSC discloses that poly end cap rounding is a conventional problem wherein an end cap does not sufficiently extend onto the surrounding oxide, resulting in undesirable leakage currents. The reference further discloses that it was conventional to avoid this problem by increasing the distance between the poly end cap and the parallel edge of the field oxide (i.e., the margin) (page 1, Discussion of Prior Art and particularly lines 30-33).

  Thus, it would have been obvious to one of ordinary skill in the art at the time of the invention that the gate in the ordinary region of the Shou reference must--or at least very preferably should-also possess an end cap margin for the purpose of preventing the undesired current leakage, as taught by NSC.
- c. Shou also depicts the strangulation region as having a semicircular shape as opposed to being formed by first, second and third edges at right angles. NSC teaches a FOX protrusion/active area recess with sides formed at right angles (see e.g., FIG 1A). It would have been obvious to one of ordinary skill in the art at the time of the invention to form the recessed portion of Shou with straight sides having right angles--at least to the extent afforded by then-existing processing techniques--as taught by NSC for conventional business reasons such as for simplifying the mask design and manufacturing process.

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should be

- 3. Claims 14-16 and 20-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shou '859/NSC '898 as applied to the claims above, and further in view of Jassowski et al. 389.
- a. As was stated above, Shou teaches either alone or in combination with NSC '898, active regions having gates extending from ordinary regions and recessed regions wherein the gate margin of the recessed region extends so that its end is in line with that of the ordinary gate's end. NSC '898 depicts (see FIGS 1A-1C) gate end caps that extend onto a recessed portion that has first and second edges extending perpendicular to the third edge thereby forming the recess. NSC further teaches that it was conventionally known that the gate margin may be increased in this situation to prevent S/D shorting or punchthrough. Neither Shou nor NSC teaches that the first edge may be longer than the second edge, as required by claims 14 and 20.
- b. Jassowski '389 depicts (See Fig 2 as labeled by the Examiner) at least one active region having an ordinary region from which gate 3 extends and having a first edge E1; a second region having a second edge E2 that is shorter than E1; and a depressed region having an edge E3 from which gate 4 extends. Both of these gates 3 and 4 have endcap margins. It would have been obvious to one skilled in the art at the time of the invention to provide an active region having a first edge that is longer than the second edge, as taught by Jassowski depending only upon the specific application for which the active region is to be employed.
- c. Claims 14 and 20 further require that the endcap margin length of the recessed gate be longer than the second length. While the margin of gate 4 is not longer, the claims nonetheless would have been obvious for the following reasons:

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- i. Jassowski teaches a lower boundary limit of having the second gate length shorter than the second edge while Shou teaches the upper boundary limit wherein the second gate length is not only longer than the second edge, it also extends to the same line as that of the first gate length. Coupling these two boundary points with the teachings of NSC--that either (1) the length of a recessed gate's margin may be increased or (2) that the lateral spacing to the edge of the field oxide may be increased in order to ensure that no shorting occurs, renders it obvious to one of ordinary skill in the art at the time of the invention that the length of the recessed gate margin could alternatively be formed of any length intermediate between these lower and upper boundary limits, depending only upon the specific application intended for the active region as this dictates various conventional details such as the channel width and length, which in turn, dictates the length and spacing requirements for the three edges of the recessed portion and the layout constraints for the circuit cell.
- ii. This position is further supported by other teachings of Jassowski.

  Specifically, gate 1 is also formed on another recessed portion. This gate is disposed so closely to the edge E5 that the gate length is set at a length of E5 + the length of the margin of gate 2. Note that E5 is less than E1. This provides support for the position that in those situations wherein a recessed gate is formed very close to an active edge (be it in the middle of an active region as set forth in claims 15 and 21 or at a corner region as depicted in the specific embodiment of Jassowski), it would have been obvious to one skilled in the art at the time of the invention to extend the gate to the same length that is set for the margin of the non-recessed region for the

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purpose of preventing shorting in case of misalignment or rounding, as taught by Jassowski and NSC.

d. Again, the foregoing analysis sets forth the boundary conditions for the recessed gate's margin length and various reasons for altering this length anywhere in between these two points. As such, these reasons also render claims 16 and 22 obvious because it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or working ranges involves only routine skill in the art. *In re Aller*, 105 USPQ 233. In the present case, the general conditions and the working ranges have been taught by the combination of the prior art references, and setting the gate length as set forth by these claims does not provide any unexpected results.

## Response to Arguments

- 4. Applicant's arguments filed 7/25/2002 have been fully considered but they are not persuasive.
- a. Applicant has argued that Shou clearly discloses that the lengths of the gate electrodes are equal and that only one of the gate electrodes extends beyond the edge of the strangulation S1 (REMARKS, page 4). Restated, Applicant acknowledges that the ends of the gates terminate at the same line and that the gate of the strangulation portion possesses an end cap, but argues that Shou does not disclose an end-cap associated with the gate of the ordinary portion of the active region. The Examiner disagrees. While FIG 3 schematically depicts the gate

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of the ordinary portion roughly terminating approximately evenly with the edge of the active region, nothing in Shou discloses that this gate does not have an end cap. Further, Applicant has not argued as to why the Examiner's position is incorrect that it would have been inherent or at least obvious to have provided an end cap on the ordinary region.

b. Applicant has asserted that the citation of Jassowski's gate G1 and edge E5 is irrelevant and therefore improper. The examiner disagrees that this teaching is either irrelevant or improper for the reasons set forth previously and restated hereinabove.

#### Conclusion

5. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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INFORMATION ON HOW TO CONTACT THE USPTO

6. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to the examiner, B. William Baumeister, at (703) 306-9165. The examiner

can normally be reached Monday through Friday, 8:30 a.m. to 5:00 p.m. If the Examiner is not

available, the Examiner's supervisor, Mr. Eddie Lee, can be reached at (703) 308-1690. Any

inquiry of a general nature or relating to the status of this application or proceeding should be

directed to the Group receptionist whose telephone number is (703) 308-0956.

B. William Baumeister

Patent Examiner, Art Unit 2815

October 14, 2002

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